

Transaction Information

Tool ID	LASC762
Tool Status	Connected
Location	Singapore
Wafer Size	300 mm
Fab Section	Lithography
Tool Available Date	2024-06-30

General Product Information

Vendor Supplier	ASML
Model	XT1900Gi
Vintage	2009
Serial No	4210
Asset Description	193nm ASML Immersion scanner
Software Version	5.1
CIM	SECS
Process	40/45nm backend

Hardware Configuration (Fab)

System Type	Description	Quantity	Status
Main System	main body	1	OK
Factory Interface	NONE	0	OK
Others			

Hardware Configuration (Subfab / Auxilliary Units)

Description	Quantity	Status
CYMER laser	1	OK
MCWC	1	OK
main body	1	OK
WISR	1	OK
WICR	1	OK
filter cabinet	1	OK
LCWC	1	OK
ACC	1	OK

Missing/Faulty Parts / Accesories List

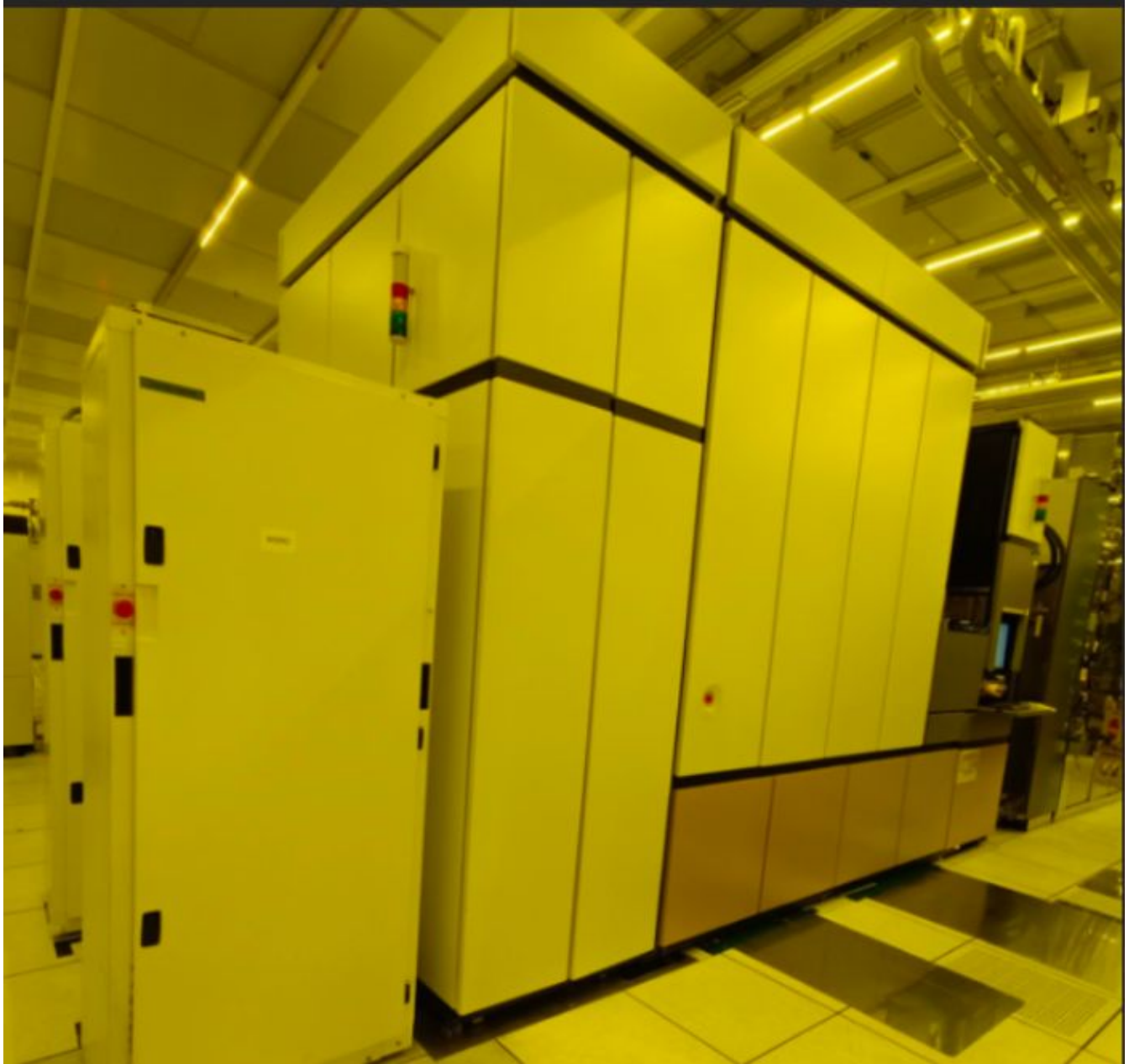
Description	Quantity
none	

Tool Pictures

Hardware Sub-fab













Additional Configuration Files